

Title (en)
ELECTRON BEAM EXCITED PHOSPHOR OR PHOSPHOR FILM AND COLOR DISPLAY UNIT UTILIZING THE SAME

Title (de)
ELEKTRONSTRAHLANGEREGETER PHOSPHOR ODER PHOSPHORFILM UND DARAUF BASIERENDE FARBDISPLAYEINHEIT

Title (fr)
PHOSPHORE EXCITÉ PAR FAISCEAU ÉLECTRONIQUE OU FILM DE PHOSPHORE ET UNITÉ D'AFFICHAGE COULEUR UTILISANT LEDIT PHOSPHORE

Publication
EP 1790709 A4 20090722 (EN)

Application
EP 05767083 A 20050728

Priority

- JP 2005013838 W 20050728
- JP 2004225688 A 20040802
- JP 2005075840 A 20050316

Abstract (en)
[origin: US2007029525A1] To provide a phosphor for an electron beam excitation with a small deterioration in an emission efficiency and capable of maintaining a high luminance, even when an excitation density of an electron beam for a phosphor excitation is increased. As raw materials, Ca₃N₂(2N), AlN(3N), Si₃N₄(3N), and Eu₂O₃(3N) are prepared, and the raw materials thus prepared are measured and mixed, so that a molar ratio of each element becomes (Ca+Eu):Al:Si=1:1:1. Then, the mixture thus obtained is maintained and fired for at 1500° C. for 3 hours, and thereafter crushed, to manufacture the phosphor having a composition formula Ca_{0.985}SiAlN₃:Eu_{0.015}.

IPC 8 full level
C09K 11/64 (2006.01); **C09K 11/66** (2006.01); **H01J 29/20** (2006.01)

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Citation (search report)

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- [A] EP 1264873 A2 20021211 - NAT INST FOR MATERIALS SCIENCE [JP]
- [A] JP 2000073053 A 20000307 - HITACHI LTD
- [A] JP 2003013059 A 20030115 - HITACHI LTD
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EP2527418A4; US7994700B2; US9738829B2; US10072207B2; US11084980B2; US11697765B2

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